



Status of scintillator scans

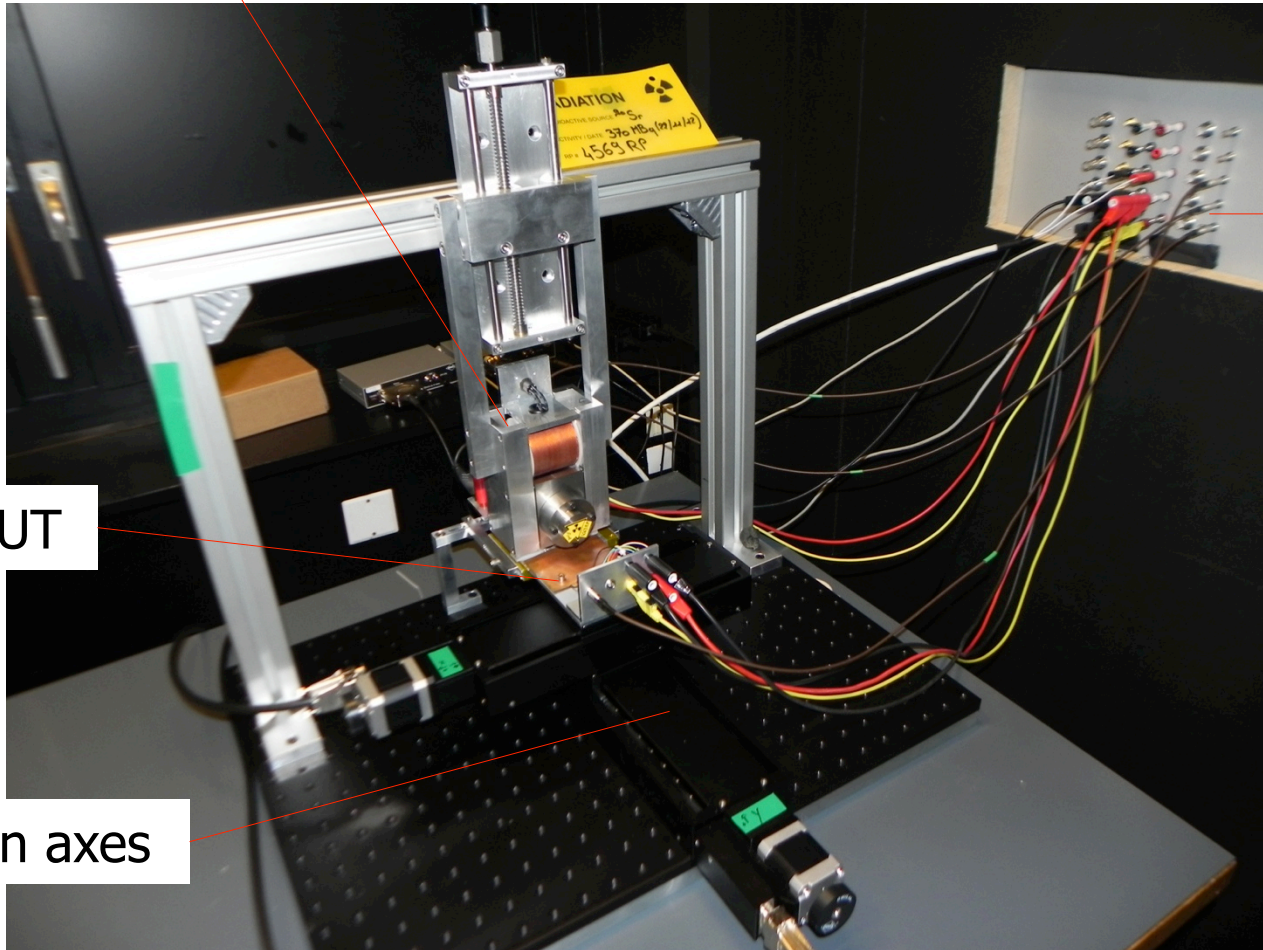
CLICdp collaboration meeting
June 11th 2014, CERN

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- Goal: R&D on CLIC ScECal with tiles at CERN
- Phase I: use scintillator scan setup to characterise various tile geometries, packaging, and SiPM couplings
- In this talk:
 - assess scintillator tiles response uniformity to MIPs
 - determine temperature correction coefficients
 - apply T-correction to full scans

Electron gun

Inside AC regulated dark room



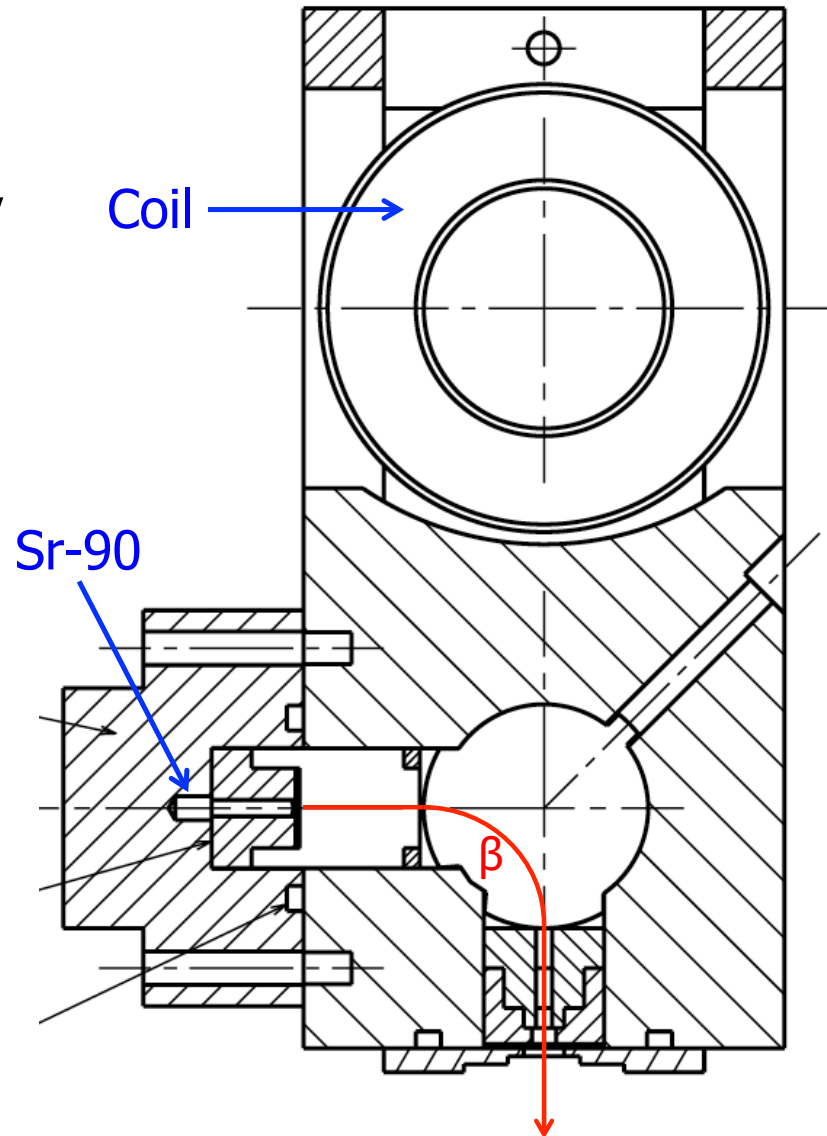
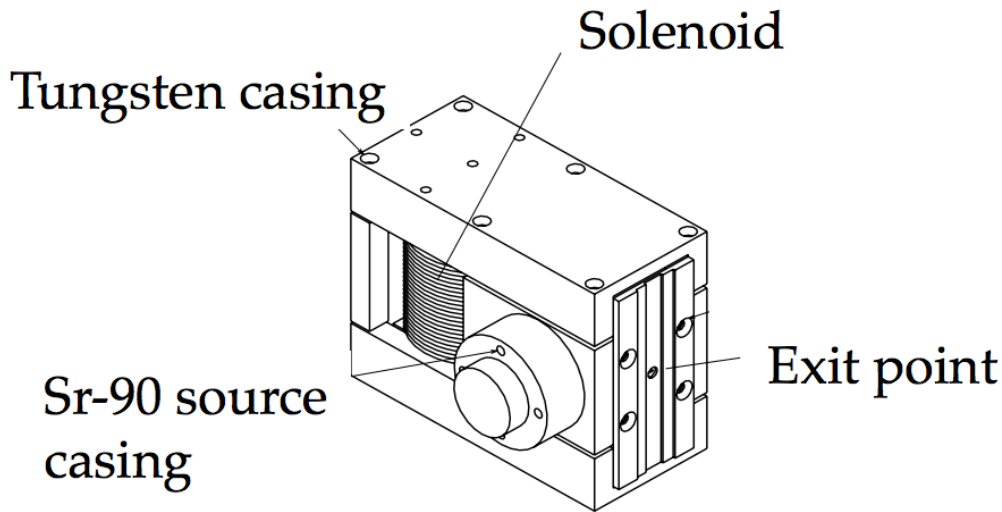
Feedthrough
to lab next
door

DUT

Translation axes

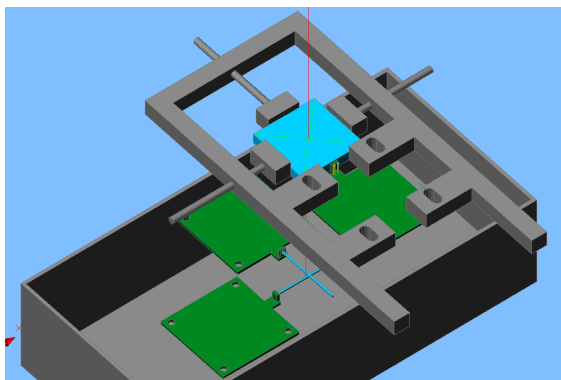
Electron gun

- ~ 350 MBq ^{90}Sr source
- Double beta emission
- Selectable energy up to ~ 2 MeV

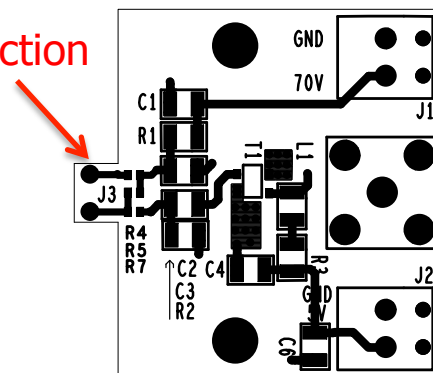


Momentum characterisation has been performed
CLICdp note under review

Readout, Trigger, and DAQ



SiPM connection



Bias V

Signal

5V

Readout

- Custom-made PCB (S. Veneziano, Rome) with amplification (~ 10) as well as temperature monitoring with PT1000 probe. Second version in development (better PCB design, 2-stage amplification).
- DUT signal is read through USB oscilloscope (Picoscope)

Trigger

- Crossed scintillating fibers ($20 \times 1 \times 1 \text{ mm}^3$) as trigger, fixed underneath DUT
- Hamamatsu MPPC (50 μm pitch) glued to painted fibre
- Trigger signals are put in coincidence (NIM) and signal goes to Picoscope

LabVIEW DAQ

- Software for calibration (auto-trigger) and data-taking (with electron source)
- Control of the step-motors for scintillator scans
- Temperature monitoring with NI DAQ Crate

Measurements performed

Two identical batches of four scintillators.

Same MPPC, same bias voltage, same electron gun current (MIPs).

Batch	Run	Size [mm ³]	Packaging	MPPC	Bias [V]	I (eGun) [A]
1	14	20x20x2	3M ESR	50µm pitch	71.3	1.4
1	13	20x20x2	Paint	50µm pitch	71.3	1.4
1	15,28	15x15x2	3M ESR	50µm pitch	71.3	1.4
1	16	15x15x2	Paint	50µm pitch	71.3	1.4
2	25,26	20x20x2	3M ESR	50µm pitch	71.3	1.4
2	27	20x20x2	Paint	50µm pitch	71.3	1.4
2	17,29	15x15x2	3M ESR	50µm pitch	71.3	1.4
2	18	15x15x2	Paint	50µm pitch	71.3	1.4

+ a series of measurements at the centre of the scintillators in order to investigate temperature sensitivity issues ==> next few slides

Batch	Run	Size [mm ³]	Packaging	<#p.e.>	± 5 % [%]	± 10 % [%]	± 20 % [%]
1	14	20x20x2	3M ESR	31	70.5	95	100
1	13	20x20x2	Paint	11	22.9	59.5	85.4
1	15 28	15x15x2	3M ESR	50 97	83.1 90.8	99.6 100	100 100
1	16	15x15x2	Paint	21	45.3	75.1	83.6
2	25 26	20x20x2	3M ESR	77 68	77.0 77.5	95.2 94.8	100 99.8
2	27	20x20x2	Paint	15	31.5	67.0	79.5
2	17 29	15x15x2	3M ESR	67 89	68.4 92.9	91.1 100	100 100
2	18	15x15x2	Paint	25	39.6	72.0	84.4

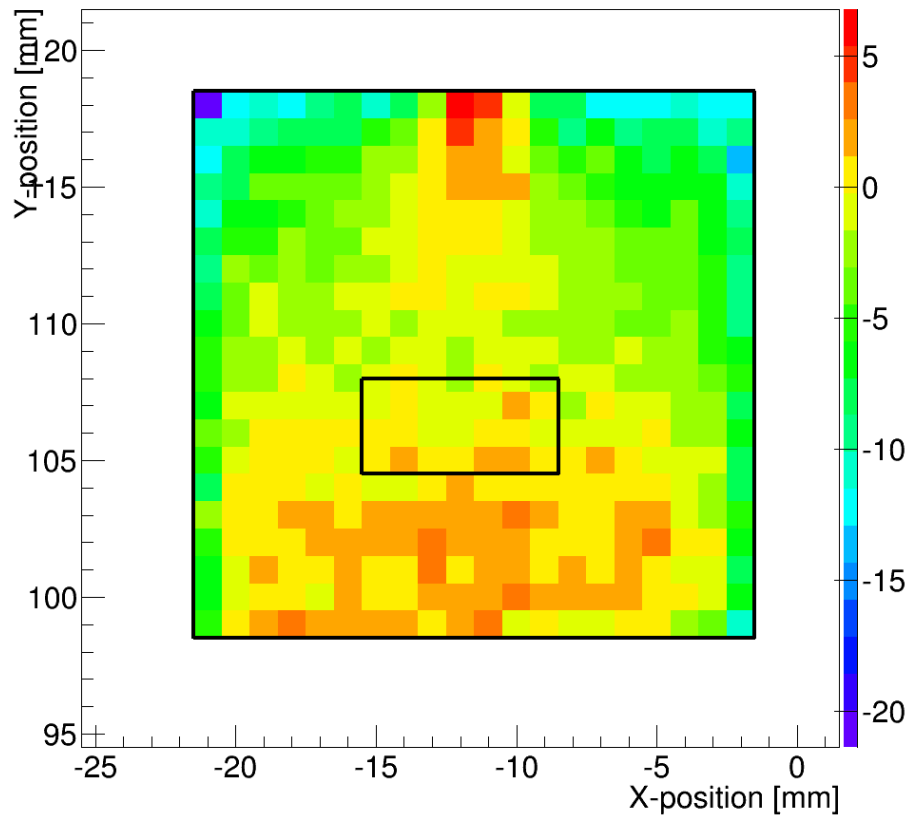
Large non-reproducibility observed, caused by:

- SiPM-scintillator coupling ==> should not touch them between measurements
- $\sim -4\%/K$ temperature correction coefficient not enough ==> determine new one

What we learned: ESR vs. Paint

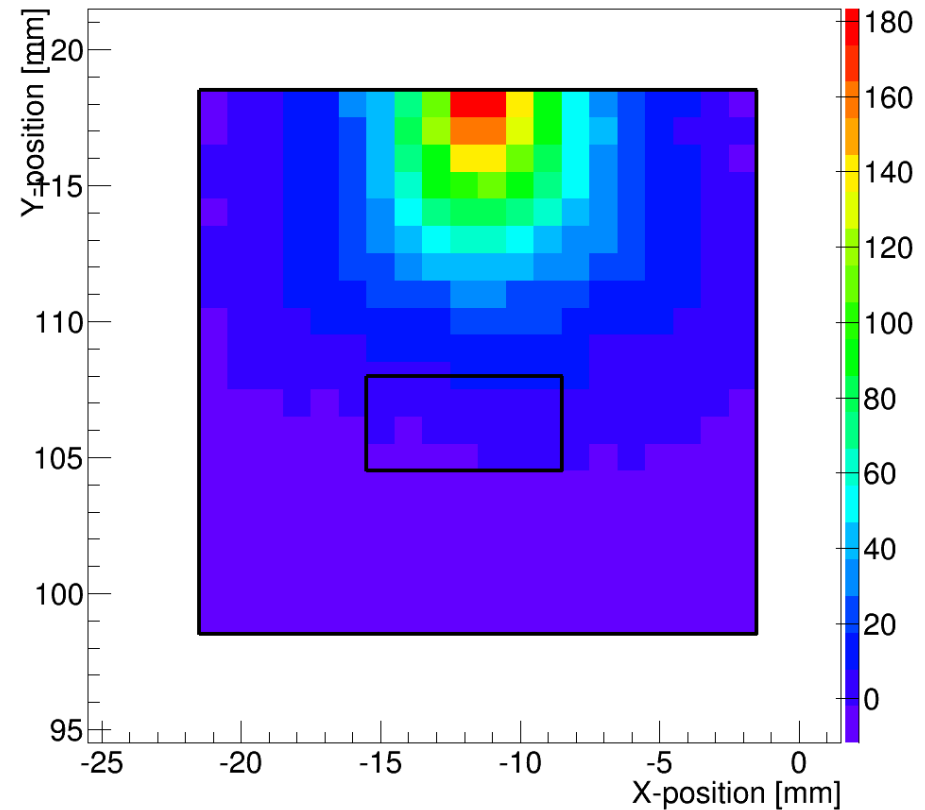
ESR¹

Relative offset from average response [%]



Paint²

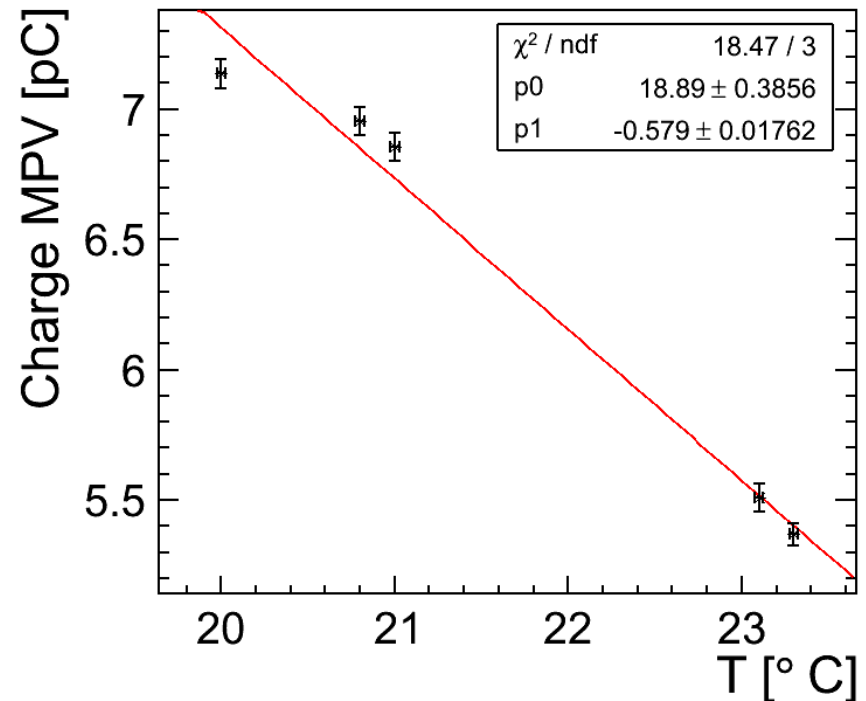
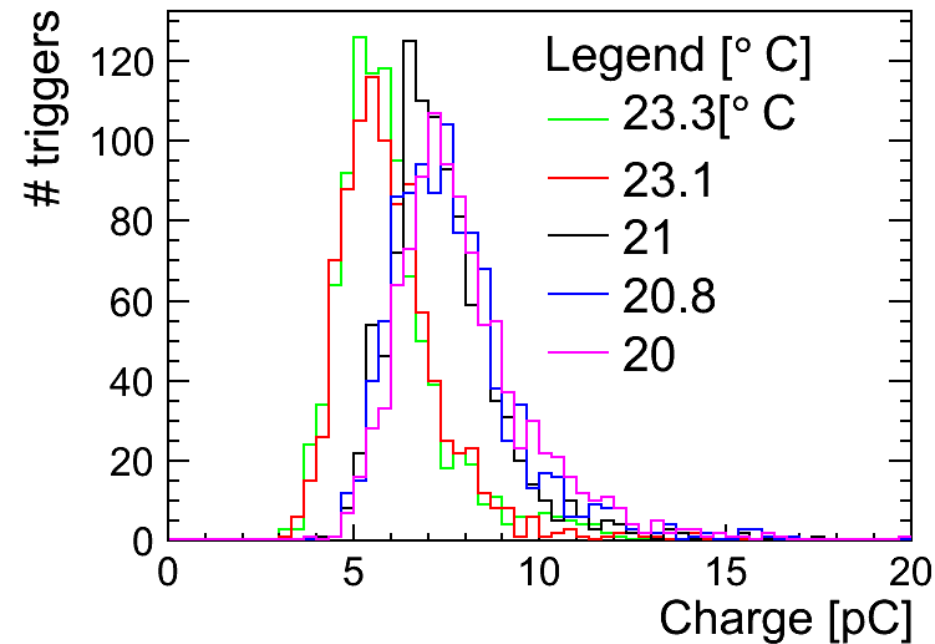
Relative offset from average response [%]



- 1) Reflective foil from 3M, held by teflon tape
- 2) Saint-Gobain BC-620 diffusive paint

Procedure:

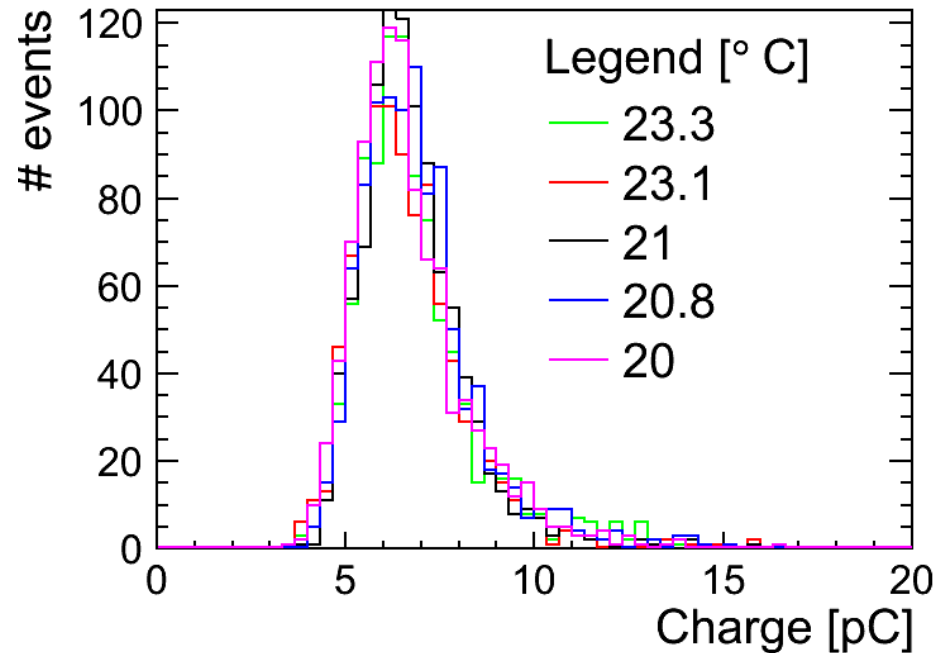
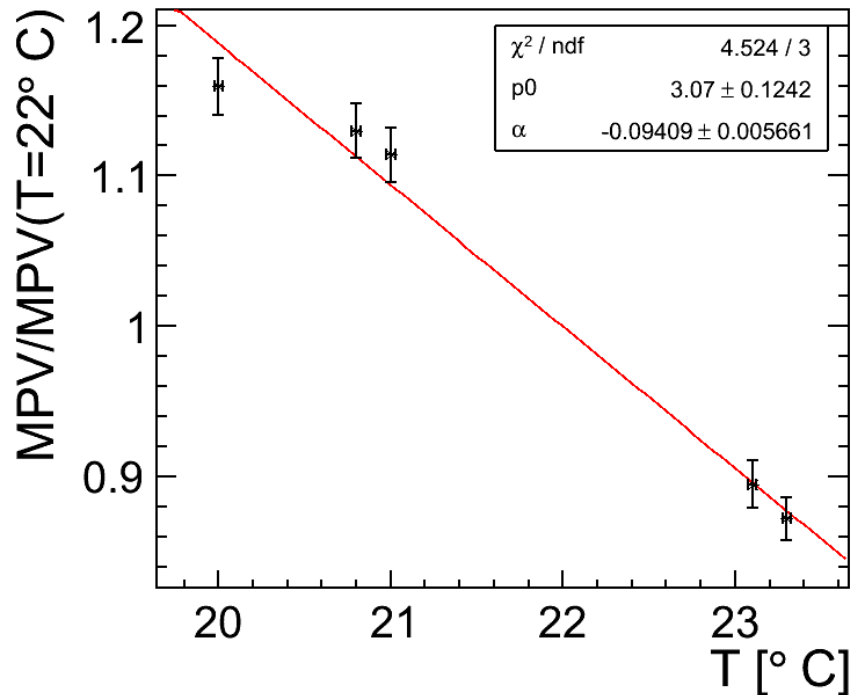
- record multiple MIP distributions from electron gun [left plot]
- same position (central), different temperatures
- fit each distribution with Landau-Gauss convolution
- linear fit of Landau MPV vs. T [right plot]



To extract temperature correction coefficient, need to define a reference temperature, we chose $T_{ref} = 22$ deg.

$$\alpha = \frac{1}{Q_{ref}} \cdot \frac{\Delta Q}{\Delta T} = -9.4\%/K$$

$$Q_{corr} = \frac{Q_{meas}}{1 + \alpha \cdot \Delta T}$$



Results after correction

	15x15 tile	20x20 tile
T_0	22°C	22°C
G_{SiPM}	43.5	43.5
α_r	-7.9 %/K	-9.4 %/K
$Mean_{ph}$	67	61
RMS_{ph}	1	2

T^{meas} [°C]	Q^{meas} [pC]	Q^{corr} [pC]	Ph^{corr} [No.]
25.1	5.1	6.7	66
21.4	6.9	6.7	67
20.8	7.4	6.8	68

15 x 15 mm²
3M wrapping

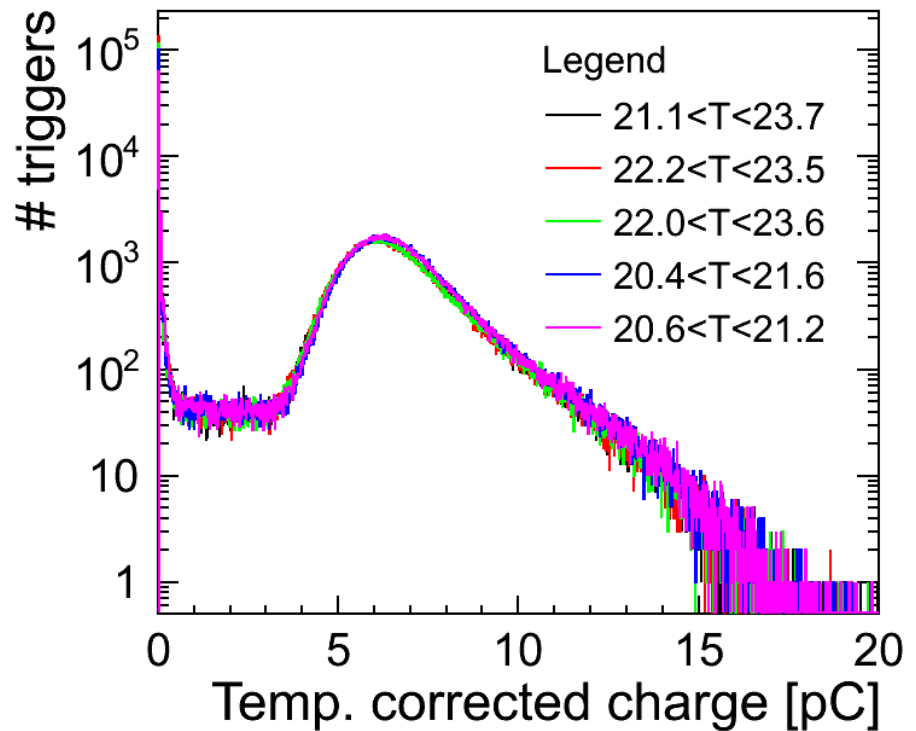
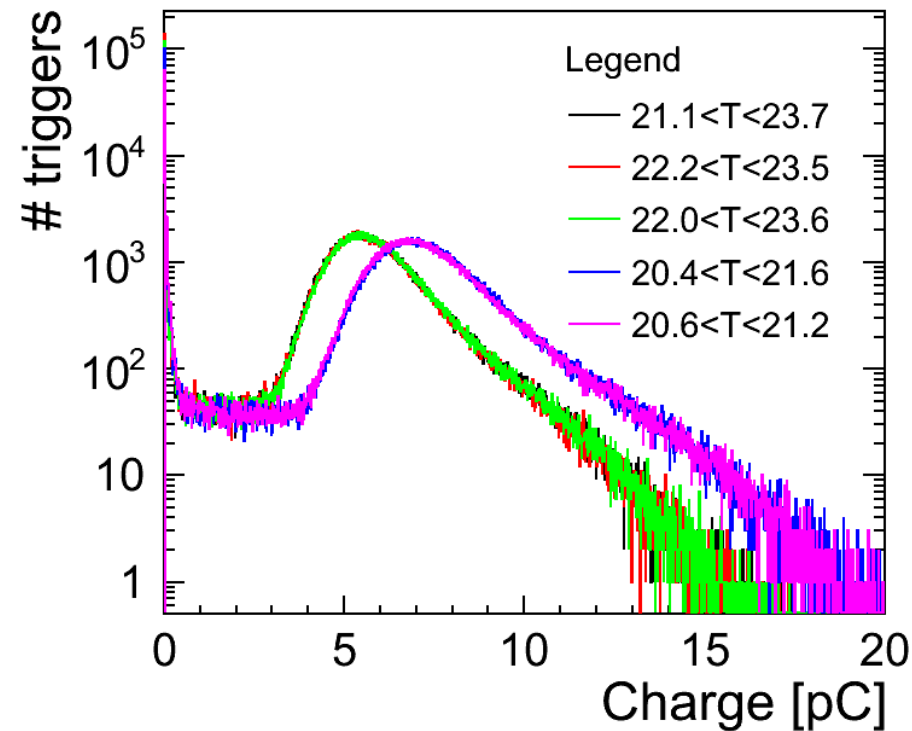
T^{meas} [°C]	Q^{meas} [pC]	Q^{corr} [pC]	Ph^{corr} [No.]
23.3	5.4	6.1	61
23.1	5.5	6.1	61
21	6.8	6.3	63
20.8	7	6.3	62
20	7.1	6	60

20 x 20 mm²
3M wrapping

Testing the correction

Applied previously determined temperature correction coefficients to full scintillator scans.

Here: 20 x 20 mm² wrapped with 3M reflective foil



- A tile-scan setup has been assembled at CERN in view of performing scintillator and SiPM studies for the CLIC ECAL R&D
- Scintillator samples of various sizes have been scanned, their uniformity assessed
 - with reflective foil and paint
 - with direct SiPM coupling to side face
- MIP response is lower with paint, but much less uniform
- SiPM coupling to scintillator shows non-reproducibility issues
- Temperature correction coefficients have been extracted and applied to full scans, reproducibility OK if we do not touch the SiPM-scintillator coupling

- Next steps:
 - quantify light yield and uniformity for new batches of 10x10, 15x15, and 20x20 mm² scintillators [this summer]
 - study readout electronics for layer prototype [FCAL AGH-UST electronics, studies have started]
 - complete hardware studies with light transport simulations in Geant4 [contributions welcome]
 - document current results as CLICdp note [ongoing]

- Measurement
 - Place selected tile in setup, coupled to the SiPM by direct contact to side face using optical grease
 - Perform self-triggered calibration run to measure gain at reference temperature
 - Switch electron gun ON, start automated tile scan with pre-selected positions
 - At each scan step (~ 60 sec):
 - Measure temperature (surface-mounted PT1000)
 - Record DUT SiPM waveform integral for each crossed-fibres coincidence signal
- Analysis
 - Correct each waveform integral by relative temperature offset w.r.t. calibration run
 - Convert waveform integral into #p.e.
 - Define tile area at the centre to calculate average response
 - For each scan position, compute deviation from $\langle \#p.e. \rangle$
 - Estimate effective tile areas within $\pm 5, 10,$ and 20% of the average response to assess response non-uniformity